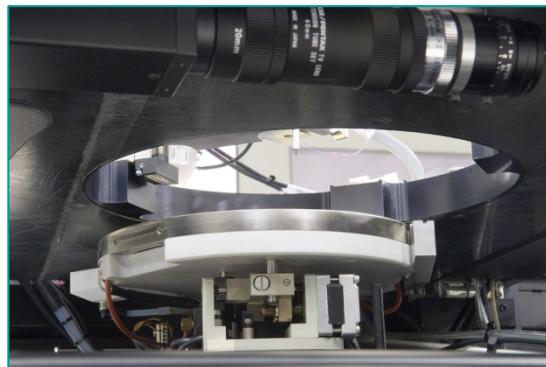
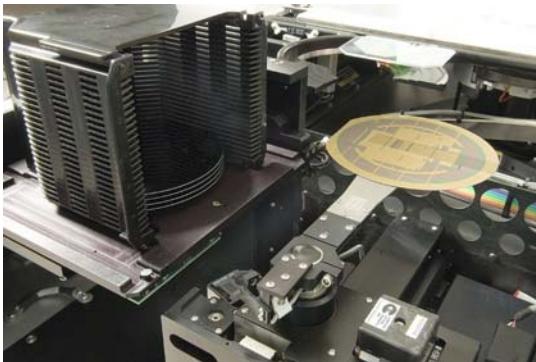




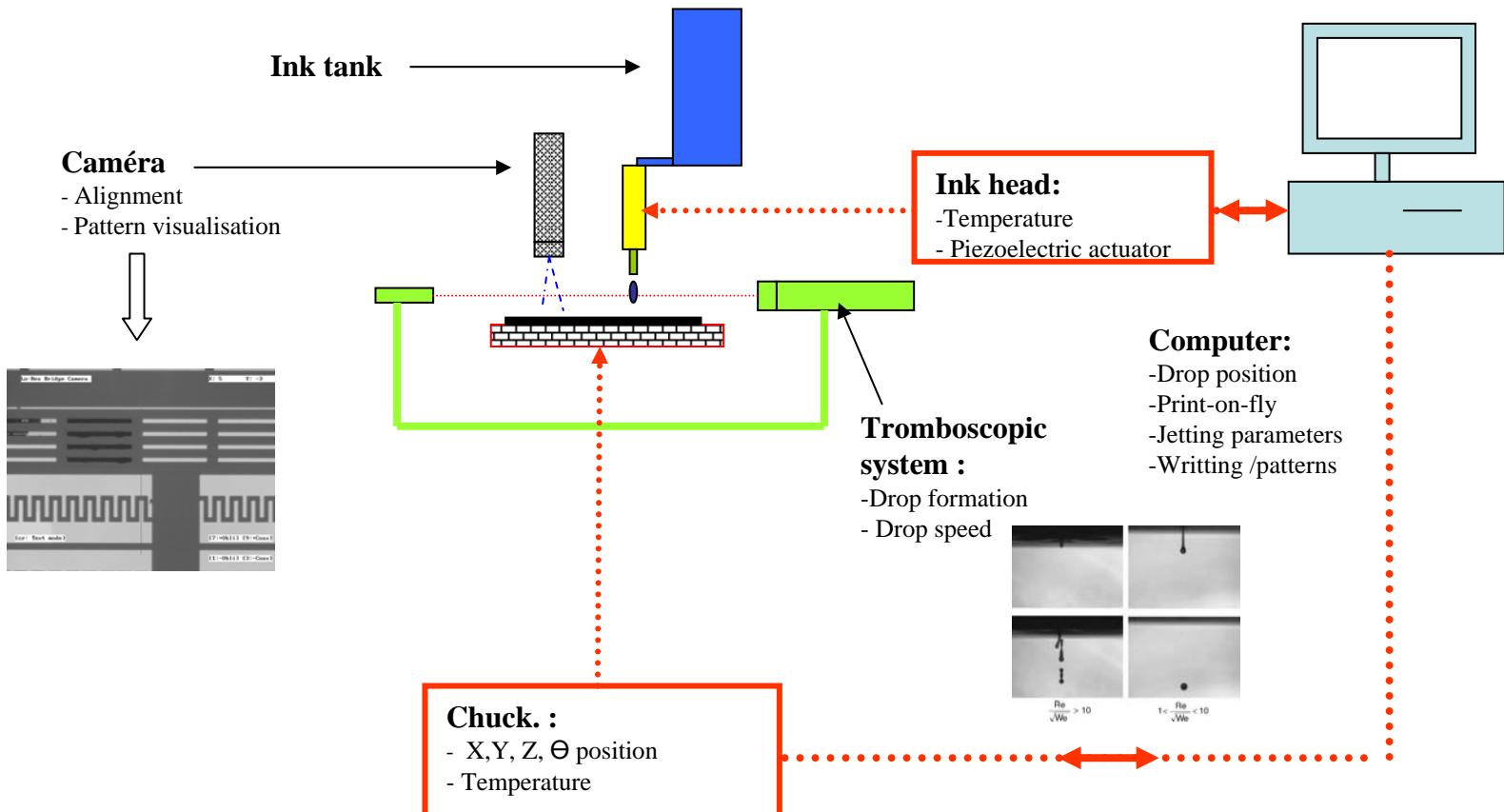
Fabrication of activated carbon electrodes by inkjet deposition

Véronique Conédéra, Fabien Mesnilgrente, Magali Brunet, Norbert Fabre
LAAS-CNRS, Université de Toulouse, 7 Av. du Colonel Roche 31077
Toulouse, France

Altatech Equipment



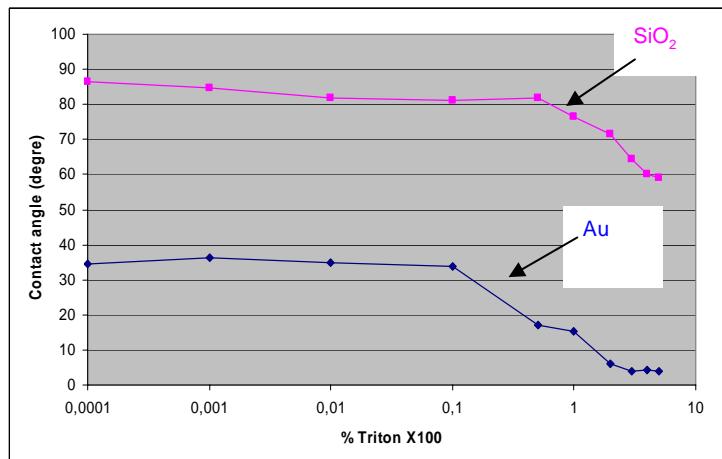
Altatech Drop-on-demand inkjet system



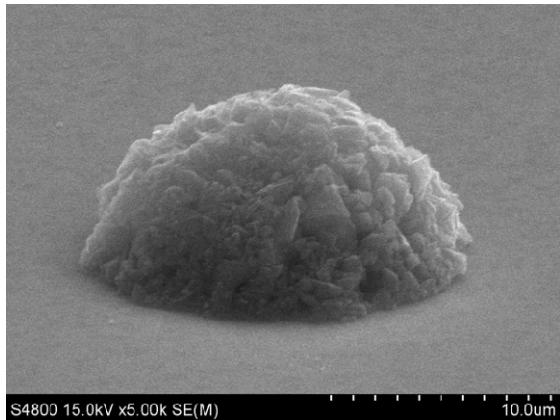
The success conditions for inkjet printing

- Ink:
 - Viscosity 0.5-20 Cp
 - Stability of the particules in suspension by controling the composition
- Substrate:
 - OTS fonctionalisation by deep coating
 - Optimisation of the contact angle
 - Hydrophilic or hydrophobic surface

PEG
AC
PTFE
Triton X100



Deposition at room temperature onto hydrophobic and hydrophilic surface



S4800 15.0kV x5.00k SE(M)

AC deposition onto a high contact angle surface of SiO₂.

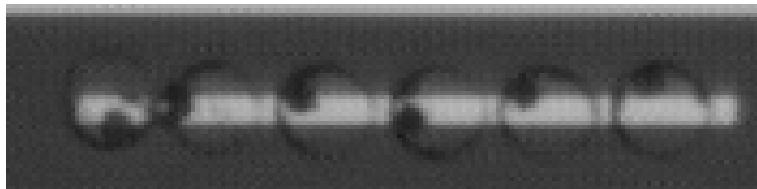
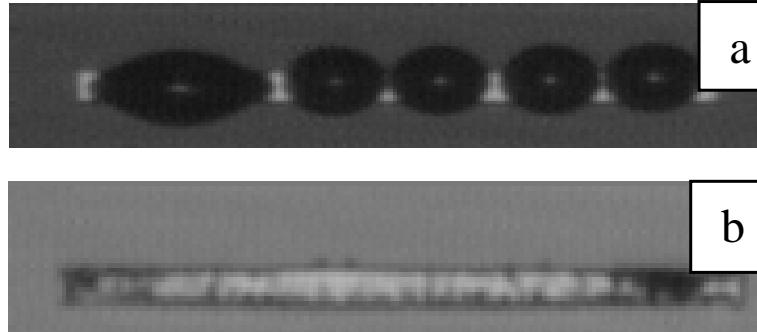


Image with 30°contact angles on Au and SiO₂.

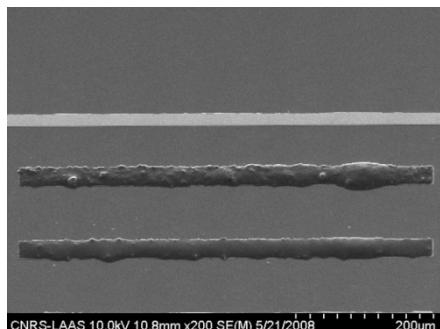


- a) Droplets after inkjet printing at room temperature
- b) Activated carbon dispersion after hot plate bake

Contact angle: Au 30° and SiO₂ 60°

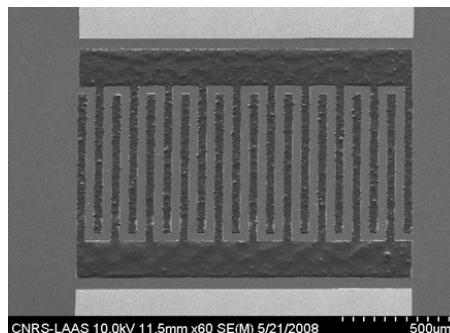
Deposition at 140°C:

linear lines

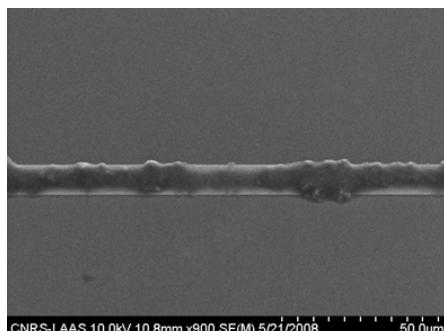


SEM of 30μm wide electrodes.
Head:50μm diameter

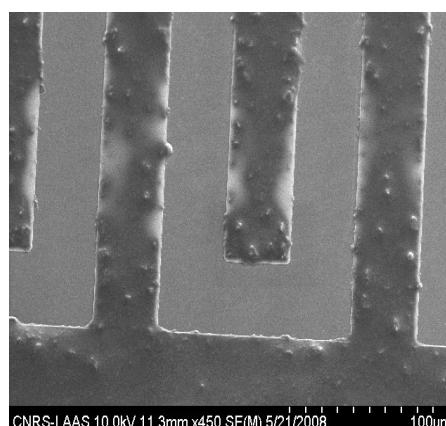
interdigitated structure
40μm lines and spaces



general view



SEM of 10μm wide electrode.



detail of the structure

Conclusion

- Method allows depositions smaller than the nozzle diameter resulting in a higher resolution .
- Possibility to write exactly on gold electrodes
- Capabilities to develop a nanoparticles deposition:
Ex; ZnO and Carbon nanotubes (CNT)